



INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification ⁷ : A61F 2/46		A2	(11) International Publication Number: WO 00/44321
			(43) International Publication Date: 3 August 2000 (03.08.00)
(21) International Application Number: PCT/IL00/00056 (22) International Filing Date: 27 January 2000 (27.01.00) (30) Priority Data: 128261 ✓ 27 January 1999 (27.01.99) IL (71) Applicant (for all designated States except US): DISC-O-TECH MEDICAL TECHNOLOGIES, LTD. [IL/IL]; Hasadnaot Street 3, 46728 Herzliya (IL). (72) Inventors; and (75) Inventors/Applicants (for US only): GLOBERMAN, Oren [IL/IL]; Derech Haganim Street 30, 46910 Kfar-Shmaryahu (IL). SHAVIT, Ronen [IL/IL]; Weinshal Street 5, 69413 Tel Aviv (IL). SHENHAV, Boaz [IL/IL]; Yehuda Hanassi Street 111, 46448 Herzliya (IL). (74) Agents: FENSTER, Paul et al.; Fenster & Company Patent Attorneys, Ltd., P.O. Box 10256, 49002 Petach Tikva (IL).		(81) Designated States: AE, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CH, CN, CR, CU, CZ, DE, DK, DM, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZW, ARIPO patent (GH, GM, KE, LS, MW, SD, SL, SZ, TZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG). Published Without international search report and to be republished upon receipt of that report.	

(54) Title: EXPANDABLE ELEMENT DELIVERY SYSTEM

(57) Abstract

Apparatus for controlling the deformation of an implant during deployment thereof, comprising: a force application mechanism for applying deforming force to the implant, by motion of a force applicator against the implant; and a restraint element positioning mechanism that positions a restraining element such that the deformation of the implant is controlled by restraint of the restraining element on allowable deformation; and a synchronizer that synchronizes the motion of the restraining element and the force applicator, to achieve a desired deformation of the implant.

